Atomically Bonded Transparent Superhydrophobic Coatings

Tolga Aytug
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Chemical Sciences Division

ATOMICALLY BONDED TRANSPARENT SUPERHYDROPHOBIC COATINGS

Tolga Aytug

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CONTENTS

LIST OF FIGURES ................................................................................................................................. iv 
ABBRREVIATED TERMS ......................................................................................................................... v 
ACKNOWLEDGMENTS ............................................................................................................................. vi 
ABSTRACT ................................................................................................................................................ 1 
1. BACKGROUND .................................................................................................................................. 1 
2. INTRODUCTION ................................................................................................................................ 2 
3. EXPERIMENTAL PROCEDURE ........................................................................................................... 2 
  3.1 PHYSICAL VAPOR DEPOSITION .......................................................................................... 3 
  3.2 TRANSFORMATION OF THE AS-DEPOSITED FILMS TO NANOSTRUCTURED 
      SUPERHYDROPHOBIC GLASS SURFACES ........................................................................ 3 
  3.3 PROPERTIES CHARACTERIZATIONS.................................................................................. 4 
      3.3.1 Water Droplet Contact Angle Measurements ....................................................... 4 
      3.3.2 Microstructural and Optical Characterization ....................................................... 5 
      3.3.3 Fracture Toughness and Abrasion Resistance Tests .............................................. 5 
4. RESULTS AND DISCUSSION ........................................................................................................... 5 
  4.1 COMPOSITIONAL ANALYSIS OF THE FILMS AND IDENTIFICATION OF 
      UNWANTED SILICA-CRUST FORMATION.......................................................................... 5 
  4.2 EFFORTS TO USE ULTRASONIC ACTIVATION DURING ETCHING TO 
      MINIMIZE SILICA-CRUST FORMATION AND REMOVAL ........................................... 8 
  4.3 EFFORTS TO PRODUCE SPATIALLY UNIFORM REMOVAL OF THE SILICA 
      CRUST ........................................................................................................................................ 9 
  4.4 ACHIEVEMENT OF TRANSPARENT SUPERHYDROPHOBIC GLASS FILMS 
      WITH ROBUST MECHANICAL PROPERTIES ................................................................... 10 
5. CONCLUSIONS ................................................................................................................................... 17 
6. REFERENCES .................................................................................................................................... 17
LIST OF FIGURES

Fig. 1. Thin glass film deposition procedure. ................................................................. 3
Fig. 2. Methods for creation of atomically bonded nanostructured superhydrophobic surfaces .......... 4
Fig. 3. Comparison of atomic percentages of silicon (Si), sodium (Na), and boron (B) with respect to (a) deposition temperature during sputtering (samples heat treated for 30 min) and (b) post thermal processing time (data is only shown for samples deposited at 400°C). ................. 6
Fig. 4. SEM image of a sputter-deposited phase-separating borosilicate thin film on a fused-quartz substrate, displaying the morphology of the surface after post thermal treatment ..................... 7
Fig. 5. Comparison of atomic percentages of Si, Na, and B for an as-deposited film and for the film after the post heat treatment. ...................................................................................... 7
Fig. 6. Optical microscope images illustrating evolution of the surface microstructure of sodium borosilicate thin films with respect to the etching process. ................................................................. 9
Fig. 7. Optical microscope images illustrating evolution of the surface microstructure of sodium borosilicate films processed using buffered oxide etch solution and ultrasonic enhancement for (a) 5 min, (b) 7 min, and (c) 10 min. ........................................................................... 10
Fig. 8. (a) Photograph of blue-dyed water droplets sitting on a superhydrophobic fused-quartz plate, displaying the transparency and superhydrophobic nature of the coating. ......................... 11
Fig. 9. SEM images illustrating (a) formation of spinodal two-phase separated structure after the heat treatment and (b) transformation of part (a) surface into a reticulated network nanostructure after the differential etching process. ......................................................... 11
Fig. 10. Photographs of a nanostructured thin-film-coated sample placed on an uncoated microscope slide (a) before and (b) after being subjected to fogging ........................................... 12
Fig. 11. (a) Optical transmittance spectra obtained through a nanostructured film surface .................. 13
Fig. 12. Scanning electron microscopy image of the Al$_2$O$_3$ particles used in the abrasion tests ........ 14
Fig. 13. (a) Schematic of the setup used to evaluate mechanical stability and durability of the superhydrophobic silica film surface under simulated dust-storm conditions (highly abrasive Al$_2$O$_3$ particles were used). ................................................. 15
Fig. 14. Atomic force microscopy images of cube-corner indentations obtained on an as-deposited and a nanotextured glass thin film. .................................................................................. 16
Fig. 15. (a) Static contact angles of water droplets on a nanostructured superhydrophobic thin film, after successive 30 min exposures to the indicated temperatures. ..................................... 16
ABBRREVIATED TERMS

BES    US Department of Energy Basic Energy Sciences Program
BOE    buffered oxide etchant
CA     contact angle
CPAC   Corrosion Prevention and Control
DOD    US Department of Defense
DOE    US Department of Energy
EDS    energy-dispersive spectroscopy
NOAA   National Oceanic and Atmospheric Administration
USMC   US Marine Corps
ORNL   Oak Ridge National Laboratory
SEM    scanning electron microscopy
STEM   scanning transmission electron microscopy
UV     ultraviolet
Z      atomic number
ACKNOWLEDGMENTS

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ABSTRACT

Maintaining clarity and avoiding the accumulation of water and dirt on optically transparent surfaces such as US military vehicle windshields, viewports, periscope optical head windows, and electronic equipment cover glasses are critical to providing a high level of visibility, improved survivability, and much-needed safety for warfighters in the field. Through a combination of physical vapor deposition techniques and the exploitation of metastable phase separation in low-alkali borosilicate, a novel technology was developed for the fabrication of optically transparent, porous nanostructured silica thin film coatings that are strongly bonded to glass platforms. The nanotextured films, initially structurally superhydrophilic, exhibit superior superhydrophobicity, hence antisoiling ability, following a simple but robust modification in surface chemistry. The surfaces yield water droplet contact angles as high as 172°. Moreover, the nanostructured nature of these coatings provides increased light scattering in the UV regime and reduced reflectivity (i.e., enhanced transmission) over a broad range of the visible spectrum. In addition to these functionalities, the coatings exhibit superior mechanical resistance to abrasion and are thermally stable to temperatures approaching 500°C. The overall process technology relies on industry standard equipment and inherently scalable manufacturing processes and demands only nontoxic, naturally abundant, and inexpensive base materials. Such coatings, applied to the optical components of current and future combat equipment and military vehicles will provide a significant strategic advantage for warfighters. The inherent self-cleaning properties of such superhydrophobic coatings will also mitigate biofouling of optical windows exposed to high-humidity conditions and can help decrease repair/replacement costs, reduce maintenance, and increase readiness by limiting equipment downtime.

1. BACKGROUND

Highly nonwetting natural biological surfaces (e.g., lotus leaves and water strider legs) have inspired strategies for the synthesis of artificial superhydrophobic surfaces that exhibit water droplet contact angles (CAs) exceeding 150°. [1-3]. Such bio-inspired, water-repellent surfaces offer significant potential for numerous uses, ranging from marine applications (e.g., antibiofouling, anticorrosion), anticondensation (e.g., antiicing, antifogging), membranes for selective separation (e.g., oil-water, gas-liquid), microfluidic systems, and surfaces requiring reduced maintenance and cleaning to applications involving glasses and optical materials [4]. For integration into commercial systems/applications that have extended operational limits and overall improved performance, surfaces that also possess multifunctional characteristics are desired, where the functionality should match the application-specific requirements. In particular, to realize the full potential for the optical and glass-based applications, surfaces might require antireflective and antifogging functionalities in addition to being mechanically robust and optically transparent [5-8]. Implicit to achieving these properties is the equally important requirement that such surfaces be produced by commercially viable manufacturing processes. To date it has been very challenging to obtain a transparent superhydrophobic medium while maintaining high optical quality and mechanical durability [9-11], mainly because the surface features necessary for hydrophobicity may lead to severe light scattering, which renders surfaces nearly opaque or translucent; moreover, surfaces with large roughness usually exhibit weak mechanical stability [12-14].

It is well known that the combined effects of appropriate surface roughness and low surface energy (i.e., surface chemistry) are responsible for superhydrophobicity [1,15,16]. An optimal rough surface morphology creates a composite air-solid interface by trapping small-scale air pockets within the film, leading to greatly reduced contact area between solid and liquid droplet, which enhances the hydrophobic properties through reduced van der Waals forces. Although superhydrophobic transparent coatings have been reported in the literature [17], the films are mostly based on roughened or porous polymers [18-20], sol-gel [21,22] and spray-on coatings [23-25], assembly of nanoarrays or nanostructures onto surfaces [26-29], and lithographic methods or template-assisted techniques [1]. Such coatings must be frequently
reapplied and are not suitable for military applications [2]. The polymer-based films are typically poorly bonded to the substrate and thus are not sufficiently durable to satisfy most application requirements [12,30,31]. In addition, the associated harsh chemical preparation procedures (i.e., use of chemical solvent mixtures) tend to degrade the physical properties of the underlying materials. Similarly, powder-based coatings exhibit poor durability due to the application-specific polymer-based binding agents. Sol-gel based coatings have a propensity for better bonding, but they generally exhibit poor hydrophobic qualities (low water CA) due to the lack of nanoscale sharpening and porosity [26,32,33]. Coatings based on nanoarrays or nanoparticles and lithographic techniques possess similar problems as polymer or sol-gel based films [13]. Furthermore, fabrication of nanostructure assemblies involves elaborate processing schemes, and in many cases the toxicity of the different reagents used in the processes poses risks to human health and concerns for the environment [26] that render them unsuitable for large-scale development and production [4].

Many of these common problems have been overcome by combining physical vapor deposition techniques (i.e., magnetron sputtering) with exploitation of metastable phase separation in low-alkali borosilicate glasses to produce differentially etched, nanostructured glass materials. The fabrication methods developed through this research rely on industry standard equipment and scalable manufacturing processes and utilize materials that are nontoxic, naturally abundant, and inexpensive.

This research is part of an overall larger effort and fits well into the strategic focus of the US Marine Corps (USMC) Corrosion Prevention and Control (CPAC) program at Oak Ridge National Laboratory (ORNL). The technology developed within the CPAC program has the potential to significantly enhance the functionality and performance of the combat vehicles and equipment that are exposed to wet and harsh environments by shedding water/moisture from the surface while providing optical clarity.

The combination of the robustness of the coating and its advanced functionality has the potential to have a huge effect in general for optical components used by all of the organizations that are under the purview of US Department of Defense (DOD). This unique technology will provide a much-needed improvement in safety, increased readiness, and an overall strategic advantage to US warfighters. In addition, the inherent self-cleaning properties of such coatings will also mitigate biofouling of optical windows used in military assets.

2. INTRODUCTION

The goal of this research was to achieve a technological leap that will enable large-area, durable superhydrophobic coatings to be applied to optically transparent surfaces of materials (glass in this case) that are not compromised by the needed ~ 600°C processing of the superhydrophobic coating. The proposed techniques have been identified as new developmental opportunities for military applications. The strategies examined in this research seek to overcome the problems encountered in earlier work and are aimed to achieve very high levels of mechanical, thermal and environmental stability for superhydrophobic coatings that can be applied to optical windows on USMC vehicles and selected equipment. Because the nanoscale surface features are smaller than the wavelengths found in visible light, the coatings are expected to be intrinsically antireflective over the visible light spectrum, providing additional functionality.

3. EXPERIMENTAL PROCEDURE

This research combines physical vapor deposition techniques to fabricate extremely uniform thin film coatings with novel methods to produce differentially etched, superhydrophobic surface-structured materials.
3.1 PHYSICAL VAPOR DEPOSITION

Physical vapor deposition processing, in particular magnetron sputtering, has been used to demonstrate the formation of uniform and strongly adhered thin films (100–500 nm thick) of an ORNL-specific sodium borosilicate glass onto fused-quartz substrates. The sputtering technique is attractive because multicomponent materials such as alloys or compounds at stoichiometric compositions can be easily deposited and because sputter coating of plate glass surfaces is a well-known industrial coating method. In addition, since sputtered species arrive at the substrate with high kinetic energy and with various angles of incidence; highly dense films with exceptional coverage can be obtained, even on irregular surfaces. Furthermore, sputtering techniques can easily be adapted for complex, continuous, and large-area depositions, which offer a unique advantage for the potential use to fabricate such coatings for a wide range of applications.

Thin-film coatings were deposited on a 2 in. sputtering target of borosilicate glass (composition 66 mole % SiO₂, 26 mole % B₂O₃, and 8 mole % Na₂O) (Fig. 1). The stoichiometry of the deposited films was carried out using energy-dispersive spectroscopy (EDS). Optical microscopy and scanning electron microscopy (SEM) were employed to identify the surface microstructure, particularly surface roughness and uniformity, of the deposited coatings.

<table>
<thead>
<tr>
<th>Approach:</th>
<th>Fabricate phase separating thin glass films (0.1-0.5 μm thick) on transparent substrates via rf-magnetron sputtering</th>
</tr>
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<tbody>
<tr>
<td>Glass target</td>
<td>Glass film deposition</td>
</tr>
<tr>
<td>(66% SiO₂, 26% B₂O₃, 8% Na₂O)</td>
<td>Glass film deposition</td>
</tr>
</tbody>
</table>

Fig. 1. Thin glass film deposition procedure.

3.2 TRANSFORMATION OF THE AS-DEPOSITED FILMS TO NANOSTRUCTURED SUPERHYDROPHOBIC GLASS SURFACES

The conversion to a superhydrophobic surface is a vital component of the methodology because it enables postdeposition transformation of the phase-separating coating into a completely adhered, transparent, and superhydrophobic thin glass film that possesses the additional functionality of visible-light antireflectivity. The conversion process can produce nanostructured materials or templates with the precise control of surface features that is required to produce both superhydrophobicity and transparency. The basic approach to make such films is to begin with phase-separating glass that is capable of spinodally decomposing (i.e., nonnucleation, continuous phase) when properly thermally processed. The phase-separated, structurally connected features scatter light due to the slight differences in the phase’s refractive indices. This light scattering is wavelength dependent and is known as Rayleigh scattering. Once the coating has been applied and phase-separated (typically by heat treating) into a spinodal pattern, a controlled level of differential etching is required to completely remove one phase and to partially remove another phase of the spinodal structure. The resulting surface structure has a very porous, reticulated network with an extremely small “funnel cake” or “coral” appearance.

The final step is to covalently bond a chemically hydrophobic self-assembled-monolayer (SAM) to the etched surface; the SAM transforms the nanostructured glass surface from hydrophilic to superhydrophobic. To be optically transparent, the underlying structure should have a texture with
features that are smaller than the smallest wavelengths found in visible light (< 400 nm). The dimensions of the desired spinodal features can be controlled by adjusting the processing parameters. Moreover, because the coating and substrate are inherently similar (virtually identical if the substrate is amorphous silica), intimately bonded materials, the resulting entity is essentially monolithic, providing advancements of both fundamental and practical significance.

More specifically, after the deposition, the surface coating is heat-treated for at least 15 to 20 min at temperatures ranging from 600°C to 710°C to produce adequate spinodal decomposition. The temperature range and the hold time are regulated based on the glass substrate material. However, a phase-separated spinodal structure is not by itself sufficient to create superhydrophobic behavior. Therefore, the heat-treated surface structure is etched with a 1:5 dilute mixture of buffered oxide etchant (BOE), (i.e., a mixture of ammonium fluoride and hydrofluoric acid) and deionized water to establish the correct volume fraction for a high-quality superhydrophobic structure. The etchant creates a nanoscale branched network by differentially eradicating all the sodium borate phase, leaving the silica-rich phase protruding from the surface. The final thickness of the film’s etched-out portion is adjusted through a combination of deposition time and variable etch parameters. To create the superhydrophobic functionality, the etched samples are immersed in a mixture of hexane and 0.5 vol % 1H;1H;2H;2H-perfluorooctyltrichlorosilane (Gelest, Inc., 95%) for 30 min and then annealed in an oven at 115°C for 15 min. The processing steps are summarized in Fig. 2.

![Fig. 2. Methods for creation of atomically bonded nanostructured superhydrophobic surfaces.](image)

### 3.3 PROPERTIES CHARACTERIZATIONS

#### 3.3.1 Water Droplet Contact Angle Measurements

Static, advancing (i.e., downhill angle), and receding (i.e., uphill angle) contact angle measurements were performed using an Attension Theta model T301 optical tensiometer (Biolin Scientific, Finland). Static contact angles were determined by taking the average of at least ten 6 μL distilled water droplets dispensed at different positions on the film. The advancing and receding angles were measured by sessile drop experiments; values were determined automatically during the growth and shrinkage of the droplet. Roll-off angles were established by using a manual tilting stage.
3.3.2 Microstructural and Optical Characterization

Plane-view surface morphology of the nanostructured films was examined using a Hitachi S-4100 high-resolution field-emission type SEM. Cross sectional microstructures were studied by Z-contrast scanning transmission electron microscopy (STEM). The Z-contrast images are sensitive to the atomic species through the atomic number (Z). Cross-sectional STEM specimens were prepared by focused ion beam milling, and the images were recorded on a Nion UltraSTEM operating at 200 kV. Surface morphology studies were performed on a VK-9700 3D laser scanning confocal microscope equipped with a 0.9 nW 408 nm laser, and optical transmittance measurements were carried out using a Cary 5000 UV-visible light–near-infrared spectrophotometer. Angle-dependent measurements were taken by rotating the specimen, where the measured angle was between the direction of the incident light and the surface normal. A Perkin-Elmer Lambda 900 spectrophotometer with two 6° relative reflectance attachments was used to measure the reflectance of the samples.

3.3.3 Fracture Toughness and Abrasion Resistance Tests

Coating indentation fracture resistance was evaluated by nanoindentation measurements using a Hysitron Triboindenter (Minneapolis, Minnesota) on films that were approximately 1 μm in thickness. Nanoindentation is a widely accepted tool for measuring the mechanical properties of thin films and small volumes of material. Although it is not an ideal test method to measure indentation fracture resistance, due to the reliance on plastic deformation of the material, nanoindentation provides information about the energy required to create and propagate a crack on the film. Measurements were performed on both as-deposited films (before the heat treatment and differential etching steps) and on the final etched product using a cube-corner indenter with a 100 nm tip radius (the cube-corner indenter was chosen due to high stress imposed in the vicinity of the contact area). Measurements were made at different loads up to the equipment’s maximum load of 10,500 μN, and the indented impressions were imaged by using the nanoindenter’s tip to provide topographical images similar to those obtained using atomic force microscopy. The penetration depth at each load was documented to determine how close the indenter tip was to the film’s interface with the substrate.

Two methodologies were invoked for the abrasion tests. The first method involved impingement of 100 g of commercial Al₂O₃ particles (irregular shapes with dimensions ranging from 100 to 300 μm) onto a superhydrophobic surface from a height of 35 cm while the sample was positioned at 45° to the horizontal surface. Al₂O₃ is widely used as an abrasive medium owing to its high hardness (9 on the Mohs scale of mineral hardness) and strength. In the second method, Al₂O₃ particles were impacted normal to the same superhydrophobic surface at a velocity of 40 to 80 km h⁻¹ for 15 min. The velocity of Al₂O₃ particles was determined from wind speed measurements using a hot wire anemometer (General Tools model CIH20DL).

4. RESULTS AND DISCUSSION

4.1 COMPOSITIONAL ANALYSIS OF THE FILMS AND IDENTIFICATION OF UNWANTED SILICA-CRUST FORMATION

Special attention was paid to the composition and surface condition of the resulting film because a thin layer of SiO₂ (termed “silica-crust”) consistently formed on the sample surfaces after the heat treatment step. Hence it was very important to understand the factors that caused the crust formation as well as to correlate the influence of sputter deposition temperature, sputter gas composition, and post-deposition heat-treatment time with the microstructure and composition of the films. Screening of the stoichiometry was carried out using EDS. The results showed systematic differences in composition of the films with
respect to the deposition temperature and heat treatment duration [Figs. 3(a) and (b)]. It is clear that while the Na signal remains relatively unchanged, Fig. 3 reveals reduced B and enhanced Si yields with respect to both increase in deposition temperature and heat treatment duration. In particular, a significant change in composition even after 30 min post-deposition thermal processing is evident from the Fig. 3(b). The change in composition clearly indicates silica-crust formation on the sample surfaces. That finding was corroborated by SEM imaging (Fig. 4) and compositional analysis (data not shown here). This behavior is not surprising considering the high volatility of B at elevated temperatures.

Films were deposited on another set of samples in an effort to understand the influence of the gas environment on the crust formation. Deposition was carried at room temperature (−25°C) and under Ar and/or a mixture of Ar/O₂ in order. Clearly, after the post-deposition thermal processing at 700°C, Si crust formation is also evident from the Fig. 5, which agrees well with the observations obtained from Figs. 3(a) and (b).

![Fig. 3. Comparison of atomic percentages of silicon (Si), sodium (Na), and boron (B) with respect to (a) deposition temperature during sputtering (samples heat-treated for 30 min) and (b) post-deposition thermal processing time (data is only shown for samples deposited at 400°C). For this set, samples were heat-treated at 710°C. All films have similar thicknesses, around 1 μm.](image)
Fig. 4. SEM image of a sputter-deposited phase-separating borosilicate thin film on a fused-quartz substrate, displaying the morphology of the surface after post-deposition thermal treatment. Regions of silica crust along with underlying spinodal film structure are visible on the sample surface.

Fig. 5. Comparison of atomic percentages of Si, Na, and B for an as-deposited film and for the film after the post-deposition heat treatment. All the films in this group were deposited at 25°C under Ar and Ar-O₂ atmosphere and thermally processed at 710°C for 30 min.

However, the slightly reduced Si and increased Na yields (after the post-deposition heat treatment) for the oxygen-processed films suggest that Na and Si are more strongly bonded in the samples and they form stoichiometric films. Observations presented in Figs. 3 and 5 are particularly important, indicating the possibility of minimizing the formation of silica crust by adjusting the processing parameters during the film growth.
4.2 EFFORTS TO USE ULTRASONIC ACTIVATION DURING ETCHING TO MINIMIZE SILICA-CRUST FORMATION AND REMOVAL

During differential etching, samples were immersed in a dilute HF solution (0.5 vol %) bath to remove the silica crust. The rate of chemical reaction was accelerated via ultrasonic activation. Optical microscopy images (Fig. 6) show evolution of sample surface morphology with respect to the etching sequence. For comparison, an image of the as-deposited sample surface after thermal processing (but before etching treatment) is displayed in Fig. 6a, revealing smooth and uniform coverage of the surface by the Si-rich crust. Figures 6(b) and (c) show changes of the surface features during etching. These images reveal that the silica crust can be etched away rather easily by employing ultrasonic activation [Fig. 6(c)], compared to the case where the film is only soaked in an acid bath [Fig. 6(b)] without any activation. The image presented in Fig. 6(c) is of the same film surface as that shown in Fig. 6(b) after being soaked in the acid bath and after being exposed to an additional ultrasonic treatment. The circular pockets in the images of Fig. 6, which represent the etched-out regions in the film, appear as raised areas or plateaus because an inverted microscope (i.e., a microscope in which light comes from above the sample stage and the lens system is below the stage) was used to obtain the images. The hill-like smooth circular plateaus in the image are the regions that are completely etched out (all the way down to the glass substrate); the rougher regions denote the areas where etchant has dissolved the silicon crust, revealing the desired nanostructured surface features.

Despite the development of surface nanostructure with prolonged HF exposure, the sizes of the completely etched-out film regions also increase [Fig. 6(c)]. Figure 6(d) displays the surface morphology of the region (by SEM) surrounding the nanostructured features where in some areas the etching process is almost complete (i.e., the film is completely etched out) and in other areas a very porous nanostructured network is clearly evident. This observation is important because superhydrophobic behavior is dependent on the volume fraction and basic nature of the etched spinodal surface structure. Hence, to achieve superhydrophobic attributes in the films, the influences of etchant type, concentration, and etch time need be clearly understood and defined. Such parameters will have to be controlled and optimized to eventually obtain the ideal surface microstructures over a large area of glass surface, such as a windshield or a viewport.
Fig. 6. Optical microscope images illustrating evolution of the surface microstructure of sodium borosilicate thin films with respect to the etching process. (a) Before etch treatment. (b) Sample without ultrasonic activation and (c) followed by ultrasonic activation [same film shown in (b)] of the etchant (etch conditions were displayed on the images). All optical images have the same magnification. (d) SEM image of a representative region of the surface where the film is gradually dissolved (sections denoted by B-1 and B-2) and completely etched out (B-3), exposing the underlying substrate.

4.3 EFFORTS TO PRODUCE SPATIALLY UNIFORM REMOVAL OF THE SILICA CRUST

Due to the difficulties with over-etching encountered with the dilute HF solution (see Sect. 4.2), a BOE solution (hydrofluoric acid mixed with NH\textsubscript{4}F as a buffering agent) was used to slow down the reaction and to provide an anisotropic chemical etch evolution for the films. BOE was employed to provide a controlled etching process for the sputtered sodium borosilicate glass films. The diluted HF solution has proven to be aggressive and resulted in overly rapid and often uncontrollable etching of the top silica crust as well as the underlying film matrix [Fig 6(b) and (c)]. Clearly such films exhibited inhomogeneous removal of the crust and hence inconsistent etching of the film matrix in various regions. By comparison, films etched with BOE at various times displayed homogeneous and controllable etch evolution and spatially uniform surface microstructures [Figs. 7(a–c)]. Figures 7(b) and (c) show uniform etch evolution, but it is also clear that the surface features disappear during extended etch times. Nevertheless, compared to isotropic etching using pure HF solution, BOE facilitates an anisotropic etching process where inward etching proceeds more quickly than the lateral etching, providing uniform removal of the silica crust and increased etch control to achieve the surface microstructure that enables superhydrophobic behavior. This is a significant breakthrough in processing. It enables reproducible fabrication of coatings on various glass substrate materials.
Fig. 7. Optical microscope images illustrating evolution of the surface microstructure of sodium borosilicate films processed using buffered oxide etch solution and ultrasonic enhancement for (a) 5 min, (b) 7 min, and (c) 10 min. Etch conditions are displayed on the images. All images have the same magnification.

4.4 ACHIEVEMENT OF TRANSPARENT SUPERHYDROPHOBIC GLASS FILMS WITH ROBUST MECHANICAL PROPERTIES

Following progress in developing parameters for deposition and etching of the thin films, a transparent superhydrophobic thin film coating was produced on a fused-quartz substrate slide. Figure 8(a) displays a photograph of an atomically bonded, transparent superhydrophobic coating on a fused-quartz substrate, revealing superhydrophobic characteristics and excellent transparency of the coating. The surface morphologies of this sample, before and after the etching step, are displayed in Figs. 9(a) and (b). Following heat treatment, an ideal, thermally induced, spinodally decomposed phase-separated structure (i.e., a structurally connected continuous phase) was observed (Fig. 9a). The etching process produced the surface morphology desired for high-quality superhydrophobic performance (a porous, reticulated network with extremely small feature size, resembling a funnel cake or coral) [Fig. 9(b)].
Fig. 8. (a) Photograph of blue-dyed water droplets sitting on a superhydrophobic fused-quartz plate, displaying the transparency and superhydrophobic nature of the coating. (b) The profile of a 6 μL water droplet placed on a similarly nanostructured film, showing a static contact angle of 172° after superhydrophobic functionalization by application of covalently bonded fluorinated organosilane groups.

Fig. 9. SEM images illustrating (a) formation of spinodal two-phase separated structure after the heat treatment and (b) transformation of part (a) surface into a reticulated network nanostructure after the differential etching process.

With an approximate pore size of 10 to 20 nm, the nanostructured silica film surface displayed in Fig. 9(b) is inherently hydrophilic and demonstrates structural superhydrophilic behavior, such that water rapidly spreads and wets the film by the capillary action. Such surfaces promote condensation to form a continuous film that spontaneously fills the nanopores, providing strong antifogging characteristics [see Figs. 10(a) and (b)]. After functionalization with organosilane molecules, the surface exhibits superhydrophobic behavior, with a static water droplet CA, θ, as large as 172° [(see Fig. 8(b)]. A more representative value of static CA over the entire surface is ~162.7°, and average advancing, θ_{adv}, and receding θ_{rec} contact angles are ~166.5° and ~163.6°, respectively. The millimetric water droplets (dyed blue) that are randomly placed on the superhydrophobic film [as shown in Fig. 8(a)] form a nearly spherical shape and easily roll off the surface at a < 5° tilt angle as a result of the small CA hysteresis of ~2.9° (i.e., the difference between θ_{adv} and θ_{rec}). Note that CA hysteresis arises from the chemical and topographical heterogeneity of the surface. Consequently, the combination of high static CA and low CA hysteresis leads to surfaces with self-cleaning ability [35]. Water droplets on such surfaces do not penetrate into the valleys (i.e., nanopores of the silica matrix in our case); rather, they are suspended on the surface prominences. Besides remarkable water-repellent properties, these bicontinuous silica films also demonstrate excellent transparency over a wide range of wavelengths (λ) and incident angles. Figure 11a compares wavelength-dependent transmittance of single-side coated and uncoated fused-quartz substrates at near normal incidence. Compared to the underlying reference template, the
superhydrophobic sample shows enhanced transmittance for wavelengths ranging from mid infrared down to ultraviolet (UV) (3000 nm ≥ λ ≥ 200 nm), remaining above 94% in the visible regime. In Fig. 8a, the clear visualization of the optical bench finish and mounting hole threads beneath the substrate further substantiates the high transparency of the nanotextured silica films. However, the measurements also showed a substantial decrease in transmittance at shorter wavelengths [see inset in Fig. 11(a)] due to increased scattering by surface features (≤ 100 nm), signifying a UV-blocking functionality.

Fig. 10. Photographs of a nanostructured thin-film-coated sample placed on an uncoated microscope slide (a) before and (b) after being subjected to fogging. Optical clarity of the sample after fogging qualitatively confirms the inherent antifogging characteristics of the nanotextured surface.

Omnidirectional characteristics of these coatings were investigated by direct transmittance measurements between 3000 nm ≥ λ ≥ 200 nm and for angles of incidence varying from 0° to 80° with 10° increments. For both coated and uncoated samples, data are presented as a hemispherical polar representation in Fig. 11(b) at two specific wavelengths covering the visible (λ = 600 nm) and UV (λ = 200 nm) region. Compared to the flat uncoated counterpart, the nanostructured surface enables slightly better transmittance at λ = 600 nm (also at other longer wavelengths; data not shown here) for all angles of
incidence, demonstrating the omnidirectional nature of the nanotextured silica films across a broad light spectrum. Measurements also verified omnidirectional UV-blocking characteristics of the coatings on the fused-quartz platforms. Protection against UV light is needed due to its harmful biological effects or to degradation of various organic and polymeric compounds, which would be important for various USMC devices employing polymeric binders or components.

**Fig. 11.** (a) Optical transmittance spectra obtained through a nanostructured film surface. For comparison, a spectrum of the uncoated fused-quartz reference is also included. Inset shows the transmittance in the UV regime. Enhanced broadband transmissivity and UV blocking performance of the coating are apparent. (b) Angular-dependent transmittance of the same samples as presented in part (a), for discrete representative wavelengths of 600 nm and 200 nm.

In addition to UV blocking functionality, the nanostructured silica films need to be mechanical and structurally stable for their effective utilization in the field. Therefore, mechanical, thermal, and
environmental robustness of the coatings for possible real-world applications (e.g., rifle scopes and other optical sensors) were assessed by performing tests of abrasion resistance, nanoindentation fracture toughness, and heat tolerance. Two complementary tests were conducted to qualify the films for abrasion resistance. First, sharp and rugged-edged Al₂O₃ particles (see Fig. 12) were impacted on a superhydrophobic surface from a height of ∼35 cm. The test was based on previously reported methods [36], but the current testing used a much more aggressive abrasive, Al₂O₃ versus SiO₂, and approximately three times more material (see Sect 3.3.3). After the test, the surface remained superhydrophobic, and the values of average static water droplet CA and roll-off angle were virtually unchanged (∼156.4° and ∼4°, respectively). In the subsequent test, outdoor dust storm conditions were simulated. An apparatus made in-house and the procedure illustrated in Fig. 13(a) were used to blast the same superhydrophobic sample with Al₂O₃ particles at a velocity (v) of 40 km h⁻¹ for 15 min. Even after that aggressive test, superhydrophobic properties were maintained. Water droplets bounced and easily rolled off the tested surface; before-test and after-test CA and roll-off angles were similar (∼155° and ∼4°, respectively). Figure 13(b) displays the appearance of the sample surface after the test. The narrow region where the water was applied and repelled is well cleaned, and the settlement of the Al₂O₃ dust on the rest of the surface is clearly apparent from the photograph, illustrating the self-cleaning property of the coating. Like many nonwetting biological systems (e.g., lotus leaves and water strider legs), such artificially created superhydrophobic surfaces can be effectively cleaned by the water droplets because the adhesion between the contaminant particles and the superhydrophobic surface is much less than the adhesion between the contaminant particles and the water droplets. For military equipment, self-cleaning ability will deliver much needed safety and functionality for soldiers, and it will also mitigate biofouling of optical windows exposed to highly humid conditions.

Fig. 12. Scanning electron microscopy image of the Al₂O₃ particles used in the abrasion tests.
Fig. 13. (a) Schematic of the setup used to evaluate mechanical stability and durability of the superhydrophobic silica film surface under simulated dust-storm conditions (highly abrasive Al₂O₃ particles were used). (b) Appearance of the sample surface after the test.

The retention of superhydrophobic attributes after the second wear test is not surprising, considering the nanostructured nature of the coating throughout the entire film thickness. That is, even if there was damage to the top surface, the film matrix below the surface is protected and possesses similar microstructure, ensuring preservation of superhydrophobic properties. To quantify the impact energy (\(E_i\)) of Al₂O₃ onto the surface, it was assumed that the particles are rectangular in shape with an average length (\(l\)), width (\(w\)), and height (\(h\)) of 200 \(\mu\)m, 100 \(\mu\)m, and 30 \(\mu\)m, respectively. This yields an estimated value of \(E_i = 1/2mv^2 = 1.46 \times 10^{-7}\)J, where \(m = lwph\) is the mass and \(\rho = 3.95\) g cm⁻³ is the density of the Al₂O₃. For comparison with the softer and smaller (50 \(\mu\)m in diameter) SiO₂ particles that would more accurately characterize real wind-storm conditions, the estimated SiO₂ particle impact energy of \(1.07 \times 10^{-8}\) J is substantially lower, signifying that the nanoscale features on the silica surface should withstand even higher windstorm velocities.

Following the abrasion tests, nanoindentation measurements were conducted to evaluate resistance to cracking or fracture. Films of approximately 1 \(\mu\)m thickness were fabricated on fused-quartz templates, and a 100 nm cube-corner indenter was used for measurements on both as-deposited dense films and on the final etched product. The method, which is based on the radial cracking that occurs when brittle materials are deformed by a sharp indenter, yields an estimation of indentation fracture toughness from measurements of crack length and maximum indentation load. Atomic force microscopy images shown in Fig. 14 illustrate the surface morphologies of a sputter-deposited film, a fully processed film, and the underlying fused-quartz substrate before and after the indentations. After application of the equipment maximum load of 10,500 \(\mu\)N, where the tip penetrated approximately 65% to 80% into the film thickness, no evidence of cracks emanating from the corners of the indented impressions was observed. Hence the indentation fracture resistance could not be quantified for the thin film materials at the maximum load of the testing equipment. Nevertheless, this result indicates that the sputter-deposited coatings, whether dense or porous, are strong and crack resistant. Compared to the underlying substrate, the dense film (before processing) releases the built-up energy in the form of material pileup on the edges of the indentation; this behavior is most likely due to the heavily strained nature of the as-deposited film, with only small reserve for further work-hardening [37]. The fact that annealed and differentially etched films do not exhibit such pileup suggests that the fully processed films accommodate strain or material movement more easily owing to their porous microstructure. Thermal stability of the coatings must also be ensured. To determine the thermal tolerance, another superhydrophobic sample (average CA \(\sim 156^\circ\)C) was iteratively annealed for 30 min in air to successive temperatures in the range from 100°C to 600°C. After each thermal exposure, the static CA at room temperature was found to remain constant for heat treatments up to at least 500°C [Fig. 15(a)], indicating excellent temperature stability of the atomically bonded nanotextured coatings. In contrast, treatment temperatures above 500°C resulted in a total loss of...
superhydrophobic performance, with CA (~17°) decreasing to those values obtained on uncoated flat glass surfaces [Fig 15(b)]. Degradation from such excessive heat treatment was attributed to burn-off of the chemically hydrophobic fluorocarbon layer.

![Fig. 14. Atomic force microscopy images of cube-corner indentations obtained on an as-deposited and a nanotextured glass thin film. Data for the underlying fused-quartz substrate are included for comparison. No cracks are observed on any sample, aside from a scratch on the fused-quartz surface due to handling.](image)

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![Fig. 15. (a) Static contact angles of water droplets on a nanostructured superhydrophobic thin film, after successive 30 min exposures to the indicated temperatures. The results demonstrate excellent thermal stability up to 500°C. (b) Profile of the water droplets (~3 μL) at successive temperatures.](image)

Fig. 15. (a) Static contact angles of water droplets on a nanostructured superhydrophobic thin film, after successive 30 min exposures to the indicated temperatures. The results demonstrate excellent thermal stability up to 500°C. (b) Profile of the water droplets (~3 μL) at successive temperatures.
5. CONCLUSIONS

The first reported atomically bonded, optically transparent, and durable superhydrophobic coatings on glass platforms were applied to at ORNL by means of the various combinations and modifications described in this report. The nanotextured films exhibit superior superhydrophobicity following a simple but durable, modification in surface chemistry, yielding water droplet contact angles as high as 172°. Moreover, the nanostructure of the coatings provides increased light scattering in the UV regime and reduced reflectivity (i.e., enhanced transmission) over a broad range of the visible spectrum. In addition to these functionalities, it was shown that the present coatings exhibit superior mechanical resistance to abrasion and that are thermally stable to temperatures approaching 500°C. The approach developed at ORNL offers potential tunability of salient functionalities for specific performance requirements and for applicability to a wide variety of glass platforms. Because the coating and substrate are inherently similar and intimately bonded materials, the resulting entity is essentially monolithic, representing a conceptually fundamental basis to be developed for leading-edge optical-quality products.

This development is part of an overall larger corrosion-mitigation program at ORNL and aligns well with the strategic focus of the USMC CPAC program. These techniques have the potential to generate thin films with very high levels of mechanical, thermal, and environmental stability while relying on standard commercial manufacturing processes that are inherently scalable and cost-effective. The intent of this effort is to significantly improve surface functionality of the optical windows (e.g., employed in periscopes, rifle scopes and vehicle windshields) by developing a well-bonded superhydrophobic thin-film coating that is virtually indistinguishable from the underlying optically transparent substrate. The ability to produce atomically bonded, transparent superhydrophobic coatings on various clear surfaces will facilitate the manufacturing of cutting-edge visibility-control products with exceptional mechanical and environmental durability. The robustness of the coating combined with its advanced functionality has the potential to have a huge effect on USMC assets as well as the assets managed by the rest of DOD. The technology that was developed within the research scope will significantly enhance the performance of current and future combat vehicles and equipment; enhance reliability, visibility, and performance; deliver much needed safety and increased readiness; and provide a strategic advantage for warfighters in the field.

6. REFERENCES